L Number	Hits	Search Text	DB	Time stamp
-	363	("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/12/19 02:14
-	102	(("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and plasma and etch$3	USPAT; EPO; JPO; DERWENT; IBM_TDB	2001/03/05 14:56
-	55	(("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))	USPAT; EPO; JPO; DERWENT; IBM_TDB	2001/03/05 15:19
-	16	((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3	USPAT; EPO; JPO; DERWENT; IBM_TDB	2001/03/05 15:20
-	0	((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and etch$3 not (((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2001/03/05 15:17
-	4	((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma not (((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2001/03/06 13:29
-	124	(("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (argon ar) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride))	USPAT; EPO; JPO; DERWENT; IBM_TDB	2001/03/05 15:21

| - | | 20 | ((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (argon ar) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride))) and plasma and etch$3 not (((((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3) (((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma not (((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3))) | USPAT; EPO; JPO; DERWENT; IBM_TDB | 2001/03/05 15:53 |

| | | 2 | (((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (argon ar) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride))) and etch$3 not ((((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3) (((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma not ((((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3)) (((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (argon ar) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride))) and plasma and etch$3 not ((((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3) (((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma not ((((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3))))) | USPAT; EPO; JPO; DERWENT; IBM_TDB | 2001/03/05 15:53 |

| - | | 16 | (((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (argon ar) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride))) and plasma not ((((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3) (((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma not ((((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3)) (((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (argon ar) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride))) and plasma and etch$3 not ((((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3) (((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma not ((((("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) and ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) and (argon ar)) and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same ("CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6 (carbon nitrogen sulfur) adj $4fluoride) same (argon ar))) and plasma and etch$3))))) | USPAT; EPO; JPO; DERWENT; IBM_TDB | 2001/03/05 15:54 |
| - | | 24 | US-Re30505-$.DID. OR US-4615764-$.DID. OR US-4793897-$.DID. OR US-5211790-$.DID. OR US-5362361-$.DID. OR US-5397431-$.DID. OR US-5721090-$.DID. OR US-5753418-$.DID. OR US-5779926-$.DID. OR US-5817579-$.DID. OR US-5910392-$.DID. OR US-5911887-$.DID. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/12/18 15:49 |

-	15	US-Re30505-$.DID. OR US-4615764-$.DID. OR US-4793897-$.DID. OR US-5211790-$.DID. OR US-5362361-$.DID. OR US-5397431-$.DID. OR US-5721090-$.DID. OR US-5753418-$.DID. OR US-5779926-$.DID. OR US-5817579-$.DID. OR US-5910392-$.DID. OR US-5911887-$.DID. OR US-6080678-$.DID. OR US-6110826-$.DID. OR US-6132631-$.DID.	USPAT	2003/12/18 15:49
-	30	US-Re30505-$.DID. OR US-4615764-$.DID. OR US-4793897-$.DID. OR US-5211790-$.DID. OR US-5362361-$.DID. OR US-5397431-$.DID. OR US-5721090-$.DID. OR US-5753418-$.DID. OR US-5779926-$.DID. OR US-5817579-$.DID. OR US-5910392-$.DID. OR US-5911887-$.DID. OR US-6080678-$.DID. OR US-6110826-$.DID. OR US-6132631-$.DID.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 15:51
-	0	WO9616437	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 15:51
-	3	"9616437"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 15:52
-	33	(US-Re30505-$.DID. OR US-4615764-$.DID. OR US-4793897-$.DID. OR US-5211790-$.DID. OR US-5362361-$.DID. OR US-5397431-$.DID. OR US-5721090-$.DID. OR US-5753418-$.DID. OR US-5779926-$.DID. OR US-5817579-$.DID. OR US-5910392-$.DID. OR US-5911887-$.DID. OR US-6080678-$.DID. OR US-6110826-$.DID. OR US-6132631-$.DID.) "9616437"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 15:59
-	15	etch$3 and DUV and (nitride Si3N4 "Si.sub.3 N.sub.4") and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same (fluoride fluorine "CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 16:37
-	0	20020003126.URPN.	USPAT	2003/12/18 16:13
-	0	20020003126.URPN.	USPAT	2003/12/18 16:13
-	1	2002-178961.NRAN.	DERWENT	2003/12/18 16:13
-	33	((US-Re30505-$.DID. OR US-4615764-$.DID. OR US-4793897-$.DID. OR US-5211790-$.DID. OR US-5362361-$.DID. OR US-5397431-$.DID. OR US-5721090-$.DID. OR US-5753418-$.DID. OR US-5779926-$.DID. OR US-5817579-$.DID. OR US-5910392-$.DID. OR US-5911887-$.DID. OR US-6080678-$.DID. OR US-6110826-$.DID. OR US-6132631-$.DID.) "9616437") not (etch$3 and DUV and (nitride Si3N4 "Si.sub.3 N.sub.4") and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same (fluoride fluorine "CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 16:17
-	99	etch$3 and (photoresist resist DUV) and (nitride Si3N4 "Si.sub.3 N.sub.4") and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same (fluoride fluorine "CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 16:38
-	119	etch$3 and (organic photoresist resist DUV) and (nitride Si3N4 "Si.sub.3 N.sub.4") and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same (fluoride fluorine "CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 16:39
-	21	(etch$3 and (organic photoresist resist DUV) and (nitride Si3N4 "Si.sub.3 N.sub.4") and (("so.sub.2" so2 (sulph?r sulfur) adj $2oxide) same (fluoride fluorine "CF.sub.4" CF4 "NF.sub.3" NF3 "SF.sub.6" SF6))) and selecti$5 same (organic photoresist resist DUV) same (nitride Si3N4 "Si.sub.3 N.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 16:40

-	4	(("RE30505") or ("5211790") or ("5753418") or ("5817579")).PN.	USPAT	2003/12/19 01:27
-	0	20020003126.URPN.	USPAT	2003/12/19 02:05
-	1	2002-178961.NRAN.	DERWENT	2003/12/19 02:05
-	6	etch$3 and ("SO.sub.2" SO2 (sulph?r sulfur) adj $2oxide) same ("SF.sub.6" SF6 (sulph?r sulfur) adj $4fluoride) and (HBr hydrogen adj bromide)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/12/19 02:22
-	5	etch$3 same (nitride SiN Si3N4 "Si.sub.3 N.sub.4" DUV resist photoresist) and ("SO.sub.2" SO2 (sulph?r sulfur) adj $2oxide) same ("SF.sub.6" SF6 (sulph?r sulfur) adj $4fluoride) and (HBr hydrogen adj bromide)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/12/19 02:21
-	2	etch$3 same (nitride SiN Si3N4 "Si.sub.3 N.sub.4" DUV resist photoresist) and ("SO.sub.2" SO2 (sulph?r sulfur) adj $2oxide) same ("SF.sub.6" SF6 (sulph?r sulfur) adj $4fluoride) same (HBr hydrogen adj bromide)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/12/19 02:21
-	29	etch$3 same (nitride SiN Si3N4 "Si.sub.3 N.sub.4" DUV resist photoresist) and ("SO.sub.2" SO2 (sulph?r sulfur) adj $2oxide) same ("SF.sub.6" SF6 (sulph?r sulfur) adj $4fluoride)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/12/19 02:22
-	60	etch$3 and ("SO.sub.2" SO2 (sulph?r sulfur) adj $2oxide) same ("SF.sub.6" SF6 (sulph?r sulfur) adj $4fluoride)	USPAT; EPO; JPO; DERWENT; IBM_TDB	2003/12/19 02:22
-	24	(US-6132631-$ or US-5911887-$ or US-6080678-$ or US-6110826-$ or US-5910392-$ or US-5362361-$ or US-5721090-$ or US-5397431-$ or US-5779926-$ or US-4615764-$ or US-4793897-$ or US-5877075-$ or US-6015597-$ or US-6617257-$ or US-6261905-$ or US-6204168-$ or US-5824604-$ or US-5798562-$ or US-5445712-$ or US-4431477-$ or US-6225220-$ or US-6149828-$).did. or (US-20010005623-$ or US-20020076935-$).did.	USPAT; US-PGPUB	2003/12/19 02:33
-	18	(etch$3 same (nitride SiN Si3N4 "Si.sub.3 N.sub.4" DUV resist photoresist) and ("SO.sub.2" SO2 (sulph?r sulfur) adj $2oxide) same ("SF.sub.6" SF6 (sulph?r sulfur) adj $4fluoride)) not ((etch$3 and ("SO.sub.2" SO2 (sulph?r sulfur) adj $2oxide) same ("SF.sub.6" SF6 (sulph?r sulfur) adj $4fluoride) and (HBr hydrogen adj bromide)) ((US-6132631-$ or US-5911887-$ or US-6080678-$ or US-6110826-$ or US-5910392-$ or US-5362361-$ or US-5721090-$ or US-5397431-$ or US-5779926-$ or US-4615764-$ or US-4793897-$ or US-5877075-$ or US-6015597-$ or US-6617257-$ or US-6261905-$ or US-6204168-$ or US-5824604-$ or US-5798562-$ or US-5445712-$ or US-4431477-$ or US-6225220-$ or US-6149828-$).did. or (US-20010005623-$ or US-20020076935-$).did.))	USPAT	2003/12/19 02:53

-	26	(etch$3 and ("SO.sub.2" SO2 (sulph?r sulfur) adj $2oxide) same ("SF.sub.6" SF6 (sulph?r sulfur) adj $4fluoride)) not ((etch$3 same (nitride SiN Si3N4 "Si.sub.3 N.sub.4" DUV resist photoresist) and ("SO.sub.2" SO2 (sulph?r sulfur) adj $2oxide) same ("SF.sub.6" SF6 (sulph?r sulfur) adj $4fluoride)) (etch$3 and ("SO.sub.2" SO2 (sulph?r sulfur) adj $2oxide) same ("SF.sub.6" SF6 (sulph?r sulfur) adj $4fluoride) and (HBr hydrogen adj bromide)) ((US-6132631-$ or US-5911887-$ or US-6080678-$ or US-6110826-$ or US-5910392-$ or US-5362361-$ or US-5721090-$ or US-5397431-$ or US-5779926-$ or US-4615764-$ or US-4793897-$ or US-5877075-$ or US-6015597-$ or US-6617257-$ or US-6261905-$ or US-6204168-$ or US-5824604-$ or US-5798562-$ or US-5445712-$ or US-4431477-$ or US-6225220-$ or US-6149828-$).did. or (US-20010005623-$ or US-20020076935-$).did.))	USPAT	2003/12/19 02:53
-	26	(US-5877075-$ or US-6149828-$ or US-6015597-$ or US-6110826-$ or US-6132631-$ or US-6080678-$ or US-5911887-$ or US-5910392-$ or US-5779926-$ or US-5721090-$ or US-5397431-$ or US-5362361-$ or US-4793897-$ or US-4615764-$ or US-6444559-$ or US-6617257-$ or US-6261905-$ or US-6204168-$ or US-5824604-$ or US-5798562-$ or US-5445712-$ or US-4431477-$ or US-6225220-$ or US-5114827-$).did. or (US-20010005623-$ or US-20020076935-$).did.	USPAT; US-PGPUB	2003/12/29 11:59
-	5	((US-5877075-$ or US-6149828-$ or US-6015597-$ or US-6110826-$ or US-6132631-$ or US-6080678-$ or US-5911887-$ or US-5910392-$ or US-5779926-$ or US-5721090-$ or US-5397431-$ or US-5362361-$ or US-4793897-$ or US-4615764-$ or US-6444559-$ or US-6617257-$ or US-6261905-$ or US-6204168-$ or US-5824604-$ or US-5798562-$ or US-5445712-$ or US-4431477-$ or US-6225220-$ or US-5114827-$).did. or (US-20010005623-$ or US-20020076935-$).did.) and (DUV deep adj (UV ultra$6))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/29 12:09
-	3	(((US-5877075-$ or US-6149828-$ or US-6015597-$ or US-6110826-$ or US-6132631-$ or US-6080678-$ or US-5911887-$ or US-5910392-$ or US-5779926-$ or US-5721090-$ or US-5397431-$ or US-5362361-$ or US-4793897-$ or US-4615764-$ or US-6444559-$ or US-6617257-$ or US-6261905-$ or US-6204168-$ or US-5824604-$ or US-5798562-$ or US-5445712-$ or US-4431477-$ or US-6225220-$ or US-5114827-$).did. or (US-20010005623-$ or US-20020076935-$).did.) and (DUV deep adj (UV ultra$6))) and (nitride sin si3n4 "si.sub.3 N.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/29 12:08

| - | | 3 | (((((US-5877075-$ or US-6149828-$ or US-6015597-$ or US-6110826-$ or US-6132631-$ or US-6080678-$ or US-5911887-$ or US-5910392-$ or US-5779926-$ or US-5721090-$ or US-5397431-$ or US-5362361-$ or US-4793897-$ or US-4615764-$ or US-6444559-$ or US-6617257-$ or US-6261905-$ or US-6204168-$ or US-5824604-$ or US-5798562-$ or US-5445712-$ or US-4431477-$ or US-6225220-$ or US-5114827-$).did. or (US-20010005623-$ or US-20020076935-$).did.) and (DUV deep adj (UV ultra$6))) and (nitride sin si3n4 "si.sub.3 N.sub.4")) and etch$3 same (nitride sin si3n4 "si.sub.3 N.sub.4") | USPAT;
US-PGPUB;
EPO; JPO;
DERWENT;
IBM_TDB | 2003/12/29 12:02 |